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Correction: Preparation of multi-layer graphene on nickel-coated silicon microchannel plates by a hydrothermal carbonization procedure and its improved field emission properties

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Correction for 'Preparation of multi-layer graphene on nickel-coated silicon microchannel plates by a hydrothermal carbonization procedure and its improved field emission properties' by Dajun Wu *et al.*, *J. Mater. Chem. C*, 2016, 4, 2079–2087.

The authors regret their oversight in omitting to attribute Fig. 2 in the above paper to their previously reported work in ref. 1. The corrected caption is shown below.

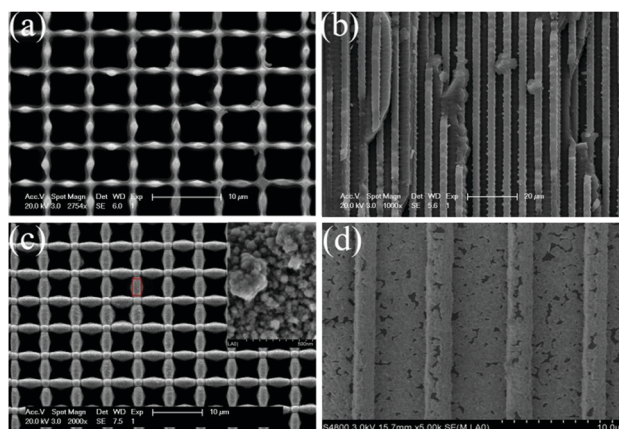


Fig. 2 SEM images: (a) Top surface of Si-MCPs. (b) Cross-sectional morphology of a. (c) Top surface of Ni/Si-MCPs with the inset showing the magnified selected area of Ni/Si-MCPs. (d) Cross-sectional morphology of the Ni/Si-MCPs. Fig. 2(a–c) were reproduced from ref. 1.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

References

- 1 D. Wu, S. Xu, M. Li, C. Zhang, Y. Zhu, Y. Xu, W. Zhang, R. Huang, R. Qi, L. Wang and P. K. Chu, *J. Mater. Chem. A*, 2015, 3, 16695–16707.

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